

Application serial No. 10/710,542  
Examiner: NELSON, VIVIAN HSU  
Art Unit: 2851

First Inventor: Ming-Chien Chiu

### **IN THE CLAIMS**

Please amend the claims as follows.

1. (currently amended) A photomask positioning apparatus, for a photomask box having a substrate comprising fixing devices formed at two sides thereof, each fixing device having a holding element for holding against a photomask, one side of the holding element having a plurality of limiting plates, a lid covering a top of the substrate and the lid enclosing a containing space for receiving the photomask, the photomask positioning apparatus comprising:

a positioning device, respectively disposed at two sides of a bottom of the containing space, the positioning device comprising a base, one end of which comprises a bended fixed portion connected to a bottom of the containing space and the other end of which is away from the fixed portion comprises a bended positioning portion such that the photomask can be positioned between the positioning portions set at the two sides of the containing space, wherein the positioning portion of the positioning device comprises a guiding surface, and wherein pulleys are set on the guiding surface.

2. (original) The photomask positioning apparatus of Claim 1, wherein the fixed portion of the positioning device further comprises a positioning slot embedded in a positioning axle set at a bottom of the containing space.

**Claim 3-4 (canceled).**

5. (original) The photomask positioning apparatus according to claim 1, wherein the positioning devices set at the two sides of the containing space can be one or more than one.

6. (currently amended) The photomask positioning apparatus according to claim 1, wherein the positioning devices is comprised of a rubber material.

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7. (currently amended) The photomask positioning apparatus according to claim 1, wherein the positioning devices is comprised of a plastic material.

8. (original) The photomask positioning apparatus according to claim 1, wherein the positioning devices are fabricated using a one-step process.

9. (currently amended) A photomask positioning apparatus, for a photomask box having a substrate comprising fixing devices formed at two sides thereof, each fixing device having a holding element for holding a photomask, a plurality of limiting plates set on one side of the holding element, a lid covering a top of the substrate and the lid enclosing a containing space for receiving the photomask, the photomask positioning apparatus comprising:

a holding device comprising a base and a holding portion, disposed one side of the containing space, wherein the base is fixed in the containing space, one side of which comprises a connecting element for setting a spindle set at a connecting end of the holding portion and other side away from the connecting end of the holding portion comprises a shifting end, and wherein a central axis connects the shifting end and the connecting end so that the holding portion can be rotated and shifted by the central axis to achieve an effect of holding.

10. (original) The photomask positioning apparatus according to claim 9, wherein a plurality of holding wheels are set on the central axis connecting the connecting end and the shifting end of the holding portion.

11. (original) The photomask positioning apparatus according to claim 10, wherein the plurality of holding wheels on the central axis is made of a soft material.

12. (original) The photomask positioning apparatus according to claim 10, wherein the plurality of holding wheels on the central axis is made of a

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Polyetheretherketone (PEEK) plastic material.

13. (original) The photomask positioning apparatus according to claim 9, wherein the shifting end of the holding portion comprises shifting wheels at other side thereof away from the central axis.

14. (original) The photomask positioning apparatus according to claim 13, wherein the shifting wheels at one side of the shifting end is made of a soft material.

15. (original) The photomask positioning apparatus according to claim 13, wherein the shifting wheels at one side of the shifting end is made of a Polyetheretherketone (PEEK) plastic material.